

PATENTS

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re APPLICATION OF:

Akira UDAGAWA, *et al.*

SERIAL NO.: TBA

FILED: February 25, 2002

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) ATTY DKT NO. 01458.00012
)
) ATTN BOX PATENT
) APPLICATIONS
)
)

FOR: RADIATION-MODIFIED POLY (TETRAFLUOROETHYLENE) RESIN FEEDS AND A
PROCESS FOR PRODUCING THE SAME

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Please amend the above-identified new application as follows.

IN THE SPECIFICATION

Page 1, following the title, please add the following new paragraph;

--This application is based upon and claims the benefit of priority from Japanese Patent
Application No. 2001-053495, filed February 28, 2001, the entire contents of this application are
incorporated herein by reference--.

IN THE CLAIMS

Please delete Claims 6-8 and insert the following Claims therein:

- 9. The process according to claim 4, wherein the ionizing radiation is selected from electron beams, x-rays, γ -rays, neutron beams and high-energy ions which are used either independently or in admixture.
10. The process according to claim 5, wherein the ionizing radiation is selected from electron beams, x-rays, γ -rays, neutron beams and high-energy ions which are used either independently or in admixture.
11. The process according to claim 4, wherein the poly (tetrafluoroethylene) resin feed is in powder form.
12. The process according to claim 5, wherein the poly (tetrafluoroethylene) resin feed is in powder

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